FORM PTO-1449

ATTY. DO 260/060

FORM PTO				ICANTIC	260/060	ET NO.	SERIAL NO. 09/574,841	20	
		ENTS AND OTHER ITEM PRMATION DISCLOSURI			APPLICANT: Mendoza, E.		<u>></u>	AUG CA	
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TRADEN			U.S. F	PATENT DOCU	JMENTS			00	
EXAMINER INITIAL		DOCUMENT NUMBER	DATE		NAME	CLASS	SUB CLASS	FILING DATE	
ACW_	AA	4,725,110	02/16/88	Glenn et al.		350/3.61		10/27/86	
	AB	5,080,503	01/14/92	Najafi et al.		385/1	-	10/01/90	
	AC	5,080,962	01/14/92	Hench		428/218		04/05/89	
	AD	5,151,958	09/29/92	Honkanen		385/50		07/26/91	
	AE	5,265,185	11/23/93	Ashley		385/132		10/02/92	
	AF	5,574,807	11/12/96	Snitzer		385/24		06/06/95	
	AG	5,620,495	04/15/97	Aspell et al.		65/392		08/16/95	
	AH	6,054,253	04/25/00	Fardad et al.		430/32		10/10/97	
V	AI	6,115,518	09/05/00	Clapp		385/37		07/17/97	
ACM	AJ	6,158,245	12/12/00	Savant		65/17.2		08/25/98	

FOREIGN PATENT DOCUMENTS								
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRAN: YES	SLATION NO
AOW	AK	WO 99/06873	02/11/99	PCT/US	C03B 32/00			X
PCN	AL_	2,218,273	04/10/99	Canada	G02B 6/136			X

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)					
ACW	AM	Mendoza E.A., Ferrell D.J., Syracuse S.J., Khalil A.N., Lieberman R.A., "Photolithography of Integrated Optice Devices in Sol-Gel Glasses," Proc. SPIE-Int. Soc. Opt. Eng., Vol. 2288, pp. 580-588 (1999)			
1		Najafi, S.I., Touam T., Sara R., Andrews M.P., Fardad M.A., "Sol-Gel Glass Waveguide and Grating on Silicon,"			
1 1	AN	Journal of Lightwave Technology, Vol. 16, No. 9 (1998)			
		McEntee J. "Sol-Gel Devices 'will meet cost targets of fibre to the home'," Opto & Laser Europe, Issue 31, p. 5			
1 1	AO	(1996)			
	AP	Coudray, P., Chisham, J., Malek-Tabrizi, A., Li, CY., Andrews, M.P., Peyghambarian, N., Najafi, S.I., "Ultraviolet Light Imprinted Sol-Gel Silica Glass Waveguide Devices on Silicon," Optics Comm., 128(1-3) 19-22 (1996).			
V	AI	Coudray, P., Chisham, J., Andrews, M.P., Najafi, S.I., "Ultraviolet Light Imprinted Sol-Gel Silica Glass Low-Loss			
ACW	AQ	Waveguides For Use At 1.55 μm," Opt. Eng. 36(4) 1234-1240 (1997)			

EXAMINER: DATE CONSIDERED	
	D: 3, 2002

EXAMINER: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include a copy of this form with next communication to applicant

ſ	FORM I	%U-144	•	260/060	00/574 841		
L	- FN	T OF DA	ATENTS AND OTHER ITEMS FOR APPLICANT'S	260/060	GROUR 1752		
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_	& TRADE			·			
-	& TRAU	, , , ,	Fardad, A., Andrews, M., Milova, G., Malek-Tabrizi		dage waveguides:: Whew		
-	10 M	AR	Solgel Route," Applied Optics, Vol. 37, No. 12., pp.	2429-2434 (1998)	no for integrated entire " Proc		
}	IPE		Najafi, S.I., Armenise, M.N., "Organoaluminophosp		ns for integrated optics, Froc.		
፞፞	` 4	AS	SPIE-Int. Soc. Opt. Eng., Vol. 2997 pp. 79-84 (1997)				
	- 1	3	Cindrich I., Lee, S.H., Sutherland, R. L., "Adapting Existing E-Beam Writers to Write HEBS-Glass Gray Masks," Proc. SPIE-Int. Soc. Opt. Eng., Vol. 3633 pp. 35-45 (1999),				
11/1	1 8 200	2 	Kley, E-B., "Continuous Profile Writing by Electron	and Ontical Lithography " Mic	roelectronic Engineering, 34		
٦		E AU		and Option Dimography, 1911	2.00.000.000.000.000.000.000.000.000.00		
<u>.</u>	- -		pp. 201-250 (1557)				
4	TRADEM	× AV	Syms, R.R.A., "Silica-On Silicon Integated Optics,"	Advances in Integrated Optics,	pp. 121-150 (1994)		
F			Najafi, S.I., Andrews, M.P., Fardad, M.A., Milova, G				
	1		Ridge and Buried Sol-Gel Glass Waveguides and De	evices on Silicon," Proc. SPIE-I	nt. Soc. Opt. Eng., Vol. 2954		
	1	AW	pp. 100-104 (1996)				
Γ			Holmes, A.S., Syms, R.R.A., "Fabrication of Low-L	oss Channel Waveguides in So	l-Gel Glass on Silicon		
L		AX	Substrates," Advanced Materials in Optics, Electro-	Optics and Communication Technologies (1995)			
	1		Holmes, A.S., Syms, R.R.A., Li, M., Green M., "Fat	abrication of Buried Channel Waveguides on Silicon Substrates			
L		AY	Using Spin-On Glass," Applied Optics, Vol. 32, No.	25 pp. 4916-4921 (1993)			
	i		Kawachi, M., "Silica Waveguides on Silicon and Th		ptic Components," Optical and		
L		AZ	AZ Quantum Electronics, Vol. 22, No. 5, pp. 391-416 (1990) Ballato, J., Dejneka, M., Riman, R.E., Snitzer, E., Zhou, W., "Sol-Gel Synthesis of Rare-Earth-Dope				
			Ballato, J., Dejneka, M., Riman, R.E., Snitzer, E., Zh	Kare-Earth-Doped Fluoride			
Ļ		BA	Glass Thin Films," Journal of Materials Research, V	01. 11, No. 4., pp. 641-649 (195	tion of Low Loss Sol Gel		
-		DD.	Yang, L., Saavedra, S.S., Armstrong, N.R., Hayes, J Planar Waveguides," Anal. Chem. Vol. 66, No. 8, pp		mon of Low-Loss, Soi-Ger		
\vdash		BB	Schmidt, H., "Thin Films, the Chemical Processing to	up to Gelation" Structure and F	Ronding Vol 77 np 119-151		
1		BC	(1992)	up to Geration, Butucture and I	7014mg, 701. 77, pp. 115 101		
+	-	- BC	Chisham, J.E., Andrews, M.P., Li, CY., Najafi, S.I.	Makek-Tabrizi, A., "Gratings	Fabrication by Ultraviolet		
1	- 1		Light Imprinting and Embossing in a Sol-Gel Silica	Glass." Proc. SPIE-Int. Soc. Or	ot. Eng., Vol. 2695, pp. 52-56		
1	- 1	BD	(1996)				
r	- 1		Svalgaard, M., Poulsen, C.V., Bjarklev A., Poulsen,	O., "Direct UV Writing of Burn	ed Singlemode Channel		
	- 1	BE	Waveguides in Ge-Doped Silica Films," Electronic I	Letters, Vol. 30, No. 17, pp. 140	01-1403 (1994)		
	1		Andrews, M.P., Kanigan T., Najafi, S.I., "Auto-Emb	oossed Bragg Gratings From Se	f-Organizing Polymers:		
	- 1		Chemical Tuning of Periodicity and Photoinduced A	nisotropy," Proc. SPIE-Int. Soc	c. Opt. Eng., Vol. 2695, pp. 4-		
L		BF	15 (1996)				
	- 1		Najafi, S. I., Li, CY., Chisham, J., Andrews, M.P., Coudray, P., Malek-Tabrizi, A., Peyghambarian, N				
	1		"Ultraviolet Light Imprinted Sol-Gel Silica Glass Ch	nannel Waveguides on Silicon,"	Proc. SPIE-Int. Soc. Opt.		
L	·	BG	Eng., Vol. 2695, pp. 38-41 (1996)		Tal Gal Saignes Academia		
Brinker, C.J., Scherer, G.W., "The Physics and Chemistry of So				mistry of Sol-Gel Processing," S	Sol-Gei Science, Academic		
-	BH Press, Inc. pp. 864-1879.			ackenzie, J.D., Peyghambarian, N., "Sol-Gel Integrated			
	}	DI	Optical Coupler by Ultraviolet Light Imprinting," El	ackenzie, J.D., reygnamoarian, lectronic Letters Vol 31 No 4	nn 271-272 (1995)		
\vdash		BI	Andrews, M.P., "An Overview of Sol Gel Guest-Ho	et Materials Chemistry for Onti	cal Devices " Proc. SPIE-Int		
	{ ,	ВЈ	Soc. Opt. Eng., Vol. 2997, pp. 48-59 (1997)	st Materials Chemistry for Opti	oui 2011003, 1100. Di 12-1111.		
┝	- \ /-	- Bi	Rösch, O.S., Bernhard, W., Müller-Fiedler, R., Dann	nhero P Bräuer A R Buestri	ch. R., Popall, M., "High		
	.₩		Performance Low Cost Fabrication Method for Integ	orated Polymer Ontical Devices	" Proc. SPIE-Int. Soc. Opt.		
	KM	ВК	Eng., Vol. 3799, pp. 214-224		,		
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Amende C. Walke	November 13,2002

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FORM PT	Ö-1449		ATTY. DOC NO.	SERIAL NO.
			260/060	09/574,841
LIST	OF PAT	ENTS AND OTHER ITEMS FOR APPLICANT'S		09/574,841 AU CROUP:
IPE		RMATION DISCLOSURE STATEMENT	APPLICANT:	0 2 1
101, 6	8		Mendoza, E. A.	
· I	8	(Use several sheets if necessary)	FILING DATE:	GROUP:
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LEGO .				-
	18/	Roscher, C., Buestrich R., Dannberg, P., Rösch, O., Po	onall, M., "New Inorganic-Or	ganic Hybrid Polymers for
& AGGERTA	BL	Integrated Optics," Mat. Res. Soc. Symp. Proc. Vol. 5		, ,
	+==	Mendoza, E.A., "Photolithography of Integrated Option		UMI Dissertation Services
2175 B	BM	(1992)	•	
1 1 7	3	Mendoza, A., Wolkow, E., Sunil, D., Wong, P., Sokol	ow, J., Rafailovich, M., den E	Boer, M., Gafney, H., "A
- 8 foot	21	Comparison of Iron Oxides Photodeposited in Porous	Vycor Glass and Tetramethon	kysilane/Methanol/Water
ADG 1 6 COUR	E BN	Xerogels," Langmuir, Vol. 7, No. 12, pp. 993-4009 (1	991)	
	3/	Che, T., Soskey, P., Banash, M., Caldwell, M., McCal	llum, I., Mininni, R., Warden,	V., "Optimization of a Gel
TRADENIE	ВО	Derived Gradient Index Material," Proc. SPIE-Int. Soc	c. Opt. Eng., Vol. 1758, pp. 19	93-204 (1992)
W INAU		Gafney, H., "A Photochemical Approach to Integrated	l Optics," J. Macromol. SciC	Chem. Vol. A27(9-11), pp.
	BP	1187-1202 (1990)	<i></i>	
	1	Simmons, K., Stegeman, G., Potter, B., Simmons, J.,	'Photosensitivity of Solgel-De	erived Germanoscilicate Planar
	BQ	Waveguides," Optics Letters, Vol. 18, No. 1, pp. 25-2	7 (1993)	, ,
		Mendoza, E., Gafney, H., "Photolithography of Integr	ated Optic Devices in Porous	Glasses," Nonlinear Optical
	BR	Materials, CRC Press, eds. Kuhn, H., Robillard, J., Pa	rt V, pp. 178-191 (1992)	<u> </u>
		Mendoza, E., Gafney, H., "Photolithographic Imaging	of Planar Optical Waveguide	es and Integrated Optic Devices
	BS	Onto Porous Silicate Glasses and Silica Sol-Gels," Ma	at. Res. Soc. Symp. Proc., Vol	1. 244, pp. 343-330 (1992)
	D.T.	Mendoza, E., Gafney, H., Morse, David, "Photolithog		ed Optic Devices in Glasses,
-	BT	SPIE Vol. 1583 Integrated Optical Circuits, pp. 43-51	vicel Concretion of Credient I	ndices in Glass "SDIE Vol
	DII	Mendoza, E., Gafney, H., Morse, D., "The Photochem	near Generation of Gradient II	nuices in Glass, SPIE voi.
 	BU	Wolkow, E., Gafney, H., Wong, P., Hanson, A., "High	hly Decolved Gradient Dattern	is in Glass by Means of
	BV	Chemical Vapor Deposition," Mat. Res. Soc. Symp. P.	toc Vol 168 nn 381-393 (1	990)
<u> </u>	I B V	Mendoza, E., Ferrell, D., Lieberman, R., "Photolithog	ranhy of Bragg Gratings in Sc	ol-Gel Derived Fibers." SPIF
Acri	BW	Vol. 2288 Sol-Gel Optics III, pp. 621-629 (1994)	input, or Drugg Cramings in or	
hu*1	12"	7 Ol. 2200 Dol-Gel Opilos III, pp. 021 029 (1994)		
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